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2-(205) 8 (201) 8 (201) Attorney Docket No. 29195-8162US

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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

Thomas L. Ritzdorf et al.

APPLICATION NO.: 09/018,783

FILED: February 4, 1998

FOR: METHOD FOR FILING RECESSED MICRO-STRUCTURES WITH METALLIZATION IN THE PRODUCTION OF A MICROELECTRONIC DEVICE

EXAMINER: D.M. COLLINS

ART UNIT: 2823

<u>Supplemental Information Disclosure Statement After First Office Action but</u> <u>Before Final Action or Notice of Allowance – 37 CFR 1.97(c)</u>

Commissioner for Patents Washington, D.C. 20231

Sir:

1. Timing of Submission

The information transmitted herewith is being filed *after* three months of the filing date of this application or after the mailing date of the first Office action on the merits, whichever occurred last, but *before* the mailing date of either a final action under 37 CFR 1.113 or a Notice of Allowance under 37 CFR 1.311, whichever occurs first. The references listed on the enclosed Form PTO/SB/08A may be material to the examination of this application; the Examiner is requested to make them of record in the application.

2. <u>Cited Information</u>

\boxtimes	Copies	of the following references are enclosed:
		All cited references References marked by asterisks The following:
	Copies	of the following references can be found in parent application Ser. No.

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02/14/2602 CU3111

		References marked by asterisks The following:
	under comm citing langua prepa langua teachi	following references are not in English. For each such reference, the signed has enclosed (i) a translation of the reference; (ii) a copy of a nunication from a foreign patent office or International Searching Authority the reference, (iii) a copy of a reference which appears to be an Englishage counterpart, or (iv) an English-language abstract for the reference red by a third party. Applicant has not verified that the translation, Englishage counterpart or third-party abstract is an accurate representation of the ngs of the non-English reference, though, and reserves the right to instrate otherwise.
		All cited references References marked by ampersands The following:
Effect	of Info	ermation Disclosure Statement (37 CFR 1.97(h))
(i) a s applic third p be, ma of int	earch hation de parties a terial t	tion Disclosure Statement is not to be construed as a representation that: as been made; (ii) additional information material to the examination of this been not exist; (iii) the information, protocols, results and the like reported by are accurate or enabling; or (iv) the cited information is, or is considered to patentability. In addition, applicant does not admit that any enclosed item on constitutes prior art to the subject invention and specifically reserves the instrate that any such reference is not prior art.
Eag D		,
Tee F	ayment	(37 CFR 1.97(c)) or Certification (37 CFR 1.97(e))
		(37 CFR 1.97(c)) or Certification (37 CFR 1.97(e)) cant elects to pay the fee under 37 CFR 1.17(p) [\$180.00].
	Applio	cant elects to pay the fee under 37 CFR 1.17(p) [\$180.00]. Check enclosed for \$180.00. Please charge the above fee(s) to Deposit Account No. 50-0665; this paper
	Applio	Check enclosed for \$180.00. Please charge the above fee(s) to Deposit Account No. 50-0665; this paper is provided in triplicate. Cant submits that no fee is due in light of the following certification under 37

3.

4.

inquiry, was known to any individual designated in 37 CFR 1.56(c), more than three months prior to the filing of this statement.

Please charge any underpayment for timely filing of this paper to Deposit Account No. 50-0665.

5. Patent Term Adjustment (37 CFR 1.704(d))

The undersigned states that each item of information submitted herewit	th was cited
in a communication from a foreign patent office in a counterpart app	lication and
that this communication was not received by any individual de	signated in
37 C.F.R. § 1.56(c) more than thirty days prior to the filing of this	statement.
37 C.F.R. § 1.704(d).	

Respectfully submitted,

Date: 28 JAN 02

Edward Hotchkiss

Registration No. 33,904

Correspondence Address:

Customer No. 25096 Phone: (206) 583-8888

Enclosures: Check

PTO/SB/08A

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Patent and Trademark Office: U.S. DEPARTMENT OF COMMERCE

Substitute for form 1449A/PTO

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Application Number	09/018,783		
Confirmation Number	1242		
Filing Date	February 4, 1998		
First Named Inventor	Ritzdorf et al.		
Group Art Unit	2823		
Examiner Name	Deven M. Collins		
Attorney Docket No.	20105 8162115		

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D.M. Cours

DATE CONSIDERED

3-22-02

Initial if reference considered, whether or not criteria is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant(s).

Approved for use through 10/31/99. OMB 0651-0031

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	luse	as many she	ets as neces	sary)	TRADE	First Named Inventor	Ritzdorf et al	
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Sheet		2	of		2	Attorney Docket No.	29195.8162U	JS
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